

02/06/02
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Docket No.: M-11543 US

February 6, 2002

Box Patent Application
Commissioner For Patents
Washington, D. C. 20231

Enclosed herewith for filing is a patent application, as follows:

Inventor: Michael D. Kilgore
Title: High Density Plasma Process For Optimum Film Quality And Electrical Results

<u>X</u>	Return Receipt Postcard;
<u>X</u>	This Transmittal Letter (in duplicate);
<u>8</u>	pages Specification (not including claims);
<u>4</u>	pages Claims;
<u>1</u>	page Abstract;
<u>1</u>	Sheet of Drawing (Fig. 1);
<u>2</u>	pages Declaration For Patent Application and Power of Attorney (signed by Michael D. Kilgore);
<u>1</u>	page Request And Certification Under 35 U.S.C. 122(b)(2)(B)(i);
<u>1</u>	page Recordation Form Cover Sheet (in duplicate);
<u>1</u>	page Assignment (signed by Michael D. Kilgore);
<u>1</u>	PTO Form 1449; and
<u>X</u>	Five Cited References.

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10/072357
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CLAIMS AS FILED

For	Number Filed		Number Extra		Rate		Basic Fee
Total Claims	20	-20 =	0	x	\$18.00	=	\$ 740.00
Independent Claims	2	-3 =	0	x	\$84.00	=	\$ 0.00
<input type="checkbox"/>	Fee of _____ for the first filing of one or more multiple dependent claims per application						\$
<input type="checkbox"/>	Fee for Request for Extension of Time						\$

Please make the following charges to Deposit Account 19-2386:

- ☒ Total fee for filing the patent application in the amount of \$ 740.00
- ☒ The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment to Deposit Account 19-2386.

EXPRESS MAIL LABEL NO:
EL 937 079 428 US

Respectfully submitted,
David E. Steuber
David E. Steuber
Attorney for Applicant
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EXPRESS MAIL LABEL NO:
EL 937 079 428 US

MODIFIED PTO/SB/35 (11-00)

REQUEST AND CERTIFICATION UNDER 35 U.S.C. 122(b)(2)(B)(i)	Inventors	Kilgore, Michael D.
	Title	High Density Plasma Process For Optimum Film Quality And Electrical Results
	Atty Docket Number	M-11543 US

I hereby certify that the invention disclosed in the attached application **has not and will not be** the subject of an application filed in another country, or under a multilateral agreement, that requires publication at eighteen months after filing. I hereby request that the attached application not be published under 35 U.S.C. 122(b).

February 6, 2002
Date



David E. Steuber
Attorney for Applicants
Reg. No.: 25,557

This request must be signed in compliance with 37 CFR 1.33(b) and submitted with the application **upon filing**.

Applicant may rescind this nonpublication request at any time. If applicant rescinds a request that an application not be published under 35 U.S.C. 122(b), the application will be scheduled for publication at eighteen months from the earliest claimed filing date for which a benefit is claimed.

If applicant subsequently files an application directed to the invention disclosed in the attached application in another country, or under a multilateral international agreement, that requires publication of applications eighteen months after filing, the applicant **must** notify the United States Patent and Trademark Office of such filing within forty-five (45) days after the date of the filing of such foreign or international application. **Failure to do so will result in abandonment of this application (35 U.S.C. 122(b)(2)(B)(iii)).**

7 CFR 1.213(a) provides for a request that an application not be published under 35 U.S.C. 122(b). Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14. SEND TO: Commissioner for Patents, Washington, DC 20231.

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